



**PennState**

# **Impact of heavy ion irradiation on GaN devices**

**Jianan Song, Martin Nate, Yuxin Du, Rongming Chu**

**In collaboration with Prof. Maik Lang , GSI & BNL**

GSI – Ar ion on-site

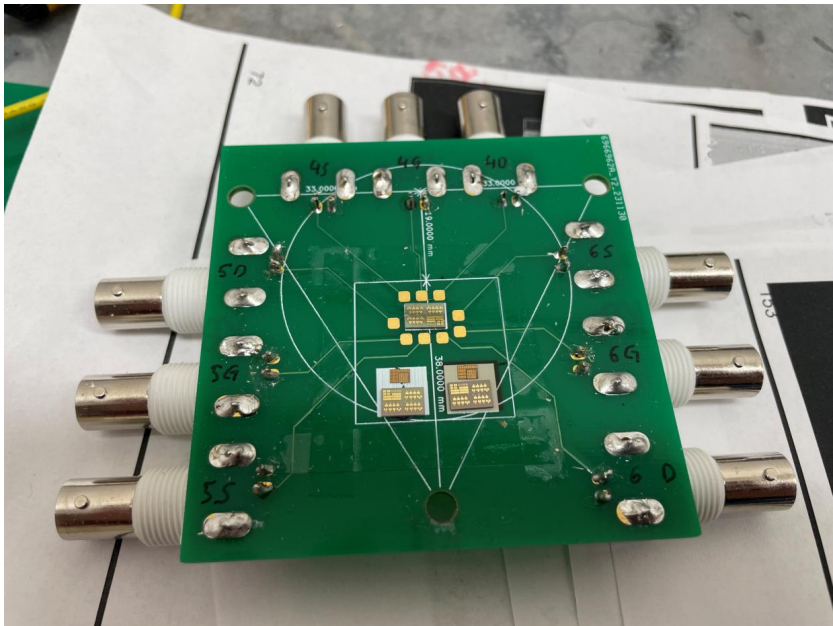
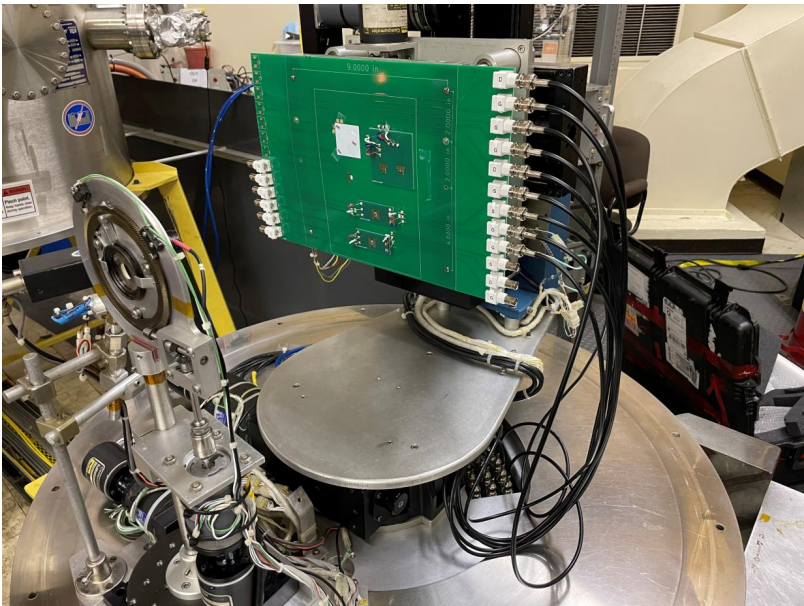
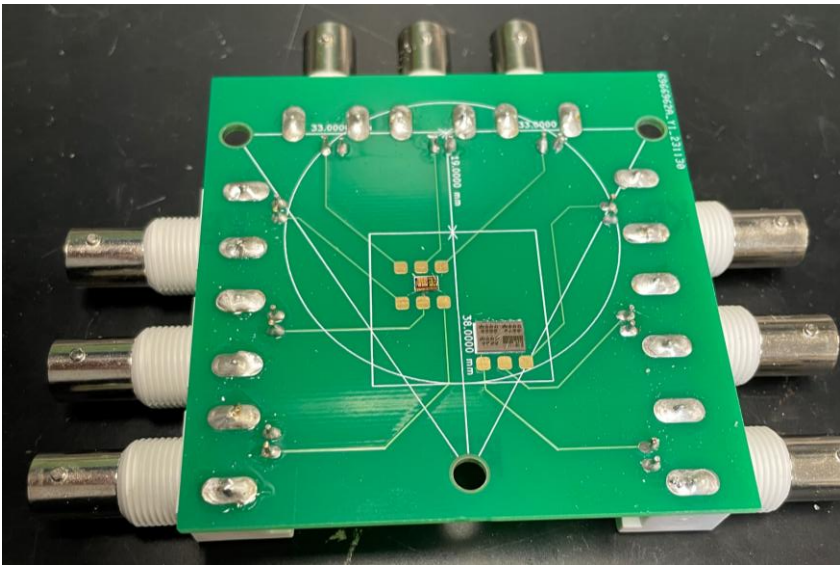
Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>40</sup> Ar	192 MeV (4.8 MeV/u)	26 μm	10.8

BNL – Au ion on-site

Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	333.7 MeV (1.71 MeV/u)	15.5 μm	~64.09

GSI – Au ion

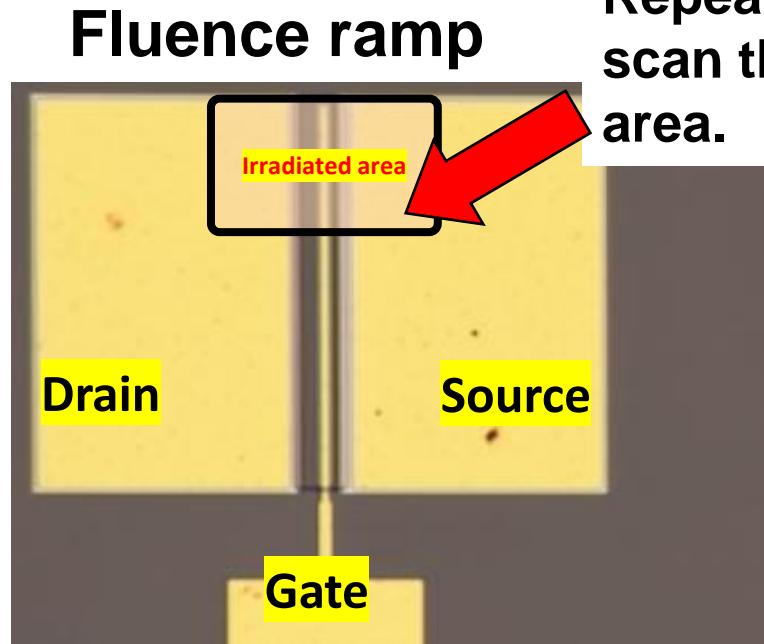
Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	950 MeV (4.8 MeV/u)	30 μm	72.4



- ❑ **GSI – 192 MeV Ar – On-site test**
- ❑ BNL – 333.7 MeV Au– On-site test
- ❑ GSI – 950 MeV Au – Ex-situ test

# Scanning recipe

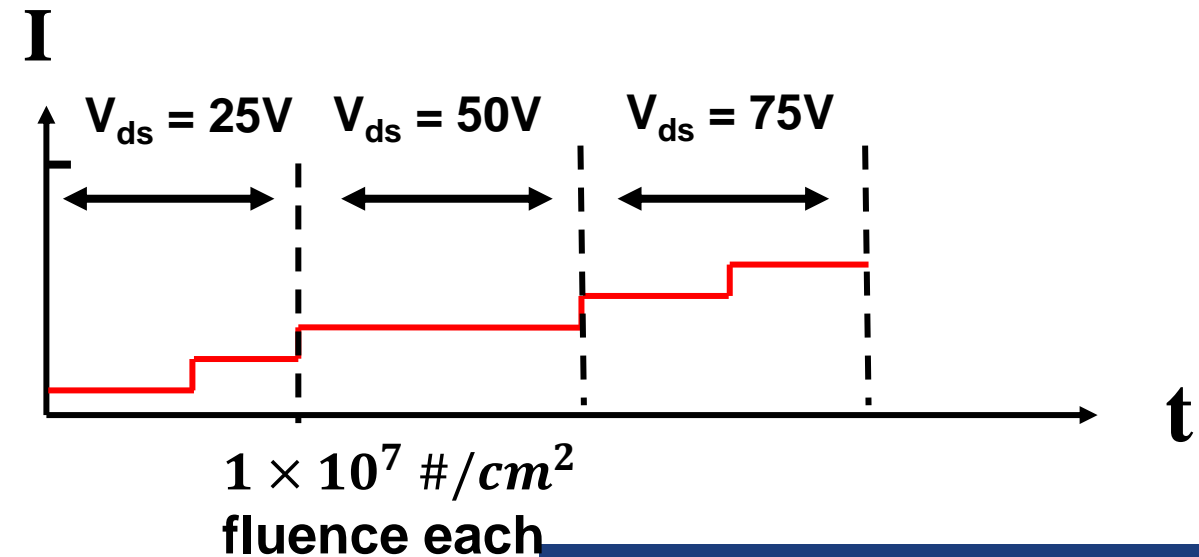
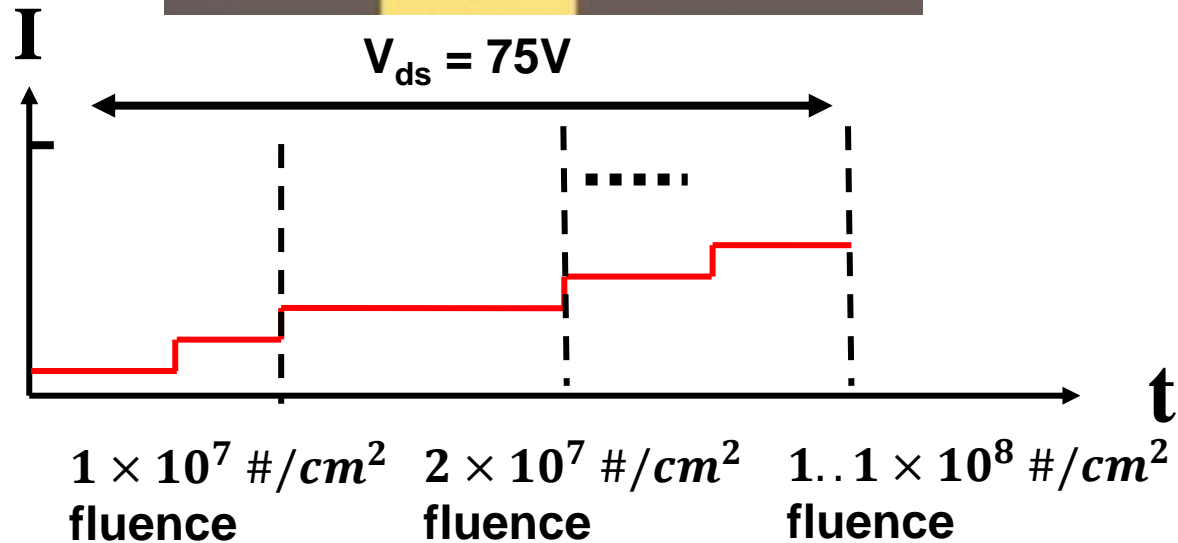
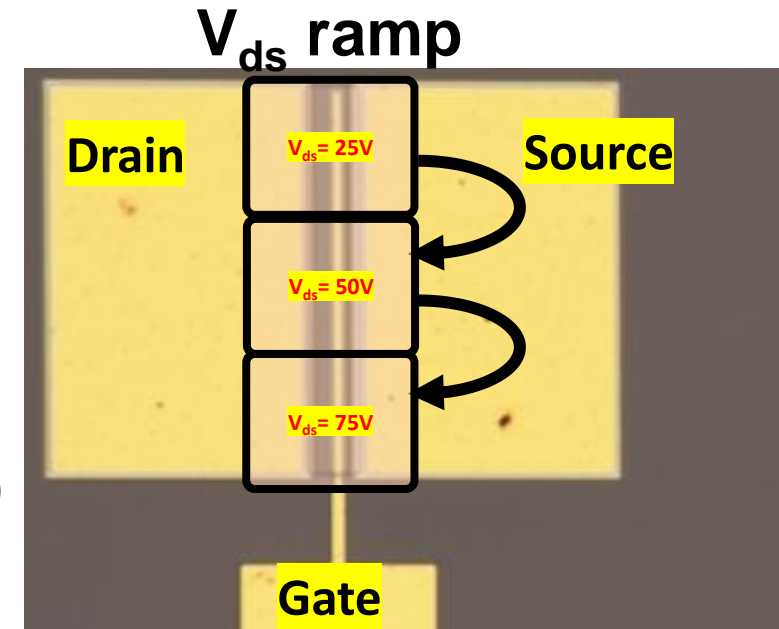
Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>40</sup> Ar	192 MeV (4.8 MeV/u)	26 μm	10.8



Repeatedly scan the area.

$BV_{ds} \approx \sim 130V$

Device bias at off-state during irradiation  
( $V_{ds}$  = variable,  $V_{gs}$  = -6 V)



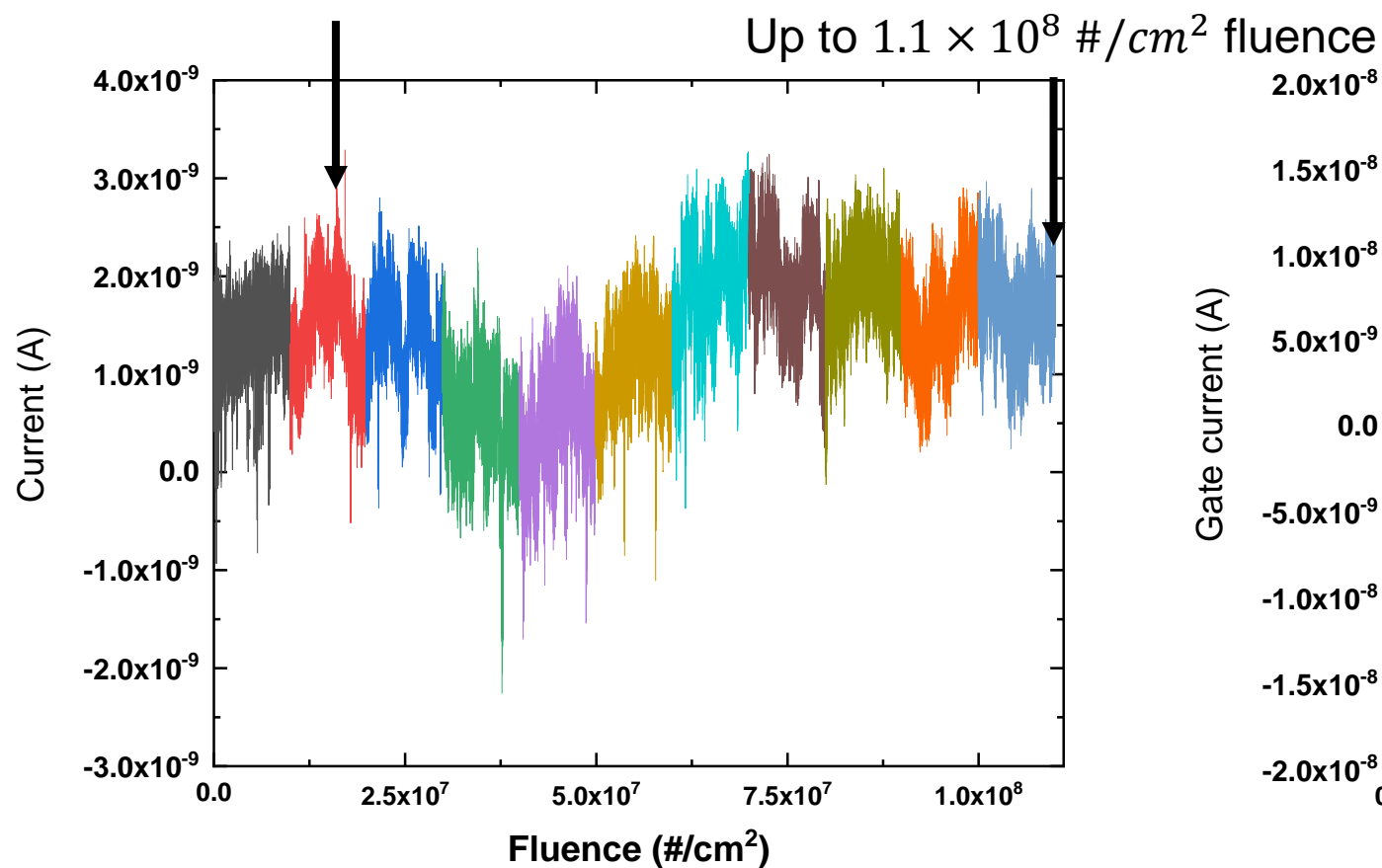
# Junction FET– Fluence ramp

Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>40</sup> Ar	192 MeV (4.8 MeV/u)	26 μm	10.8

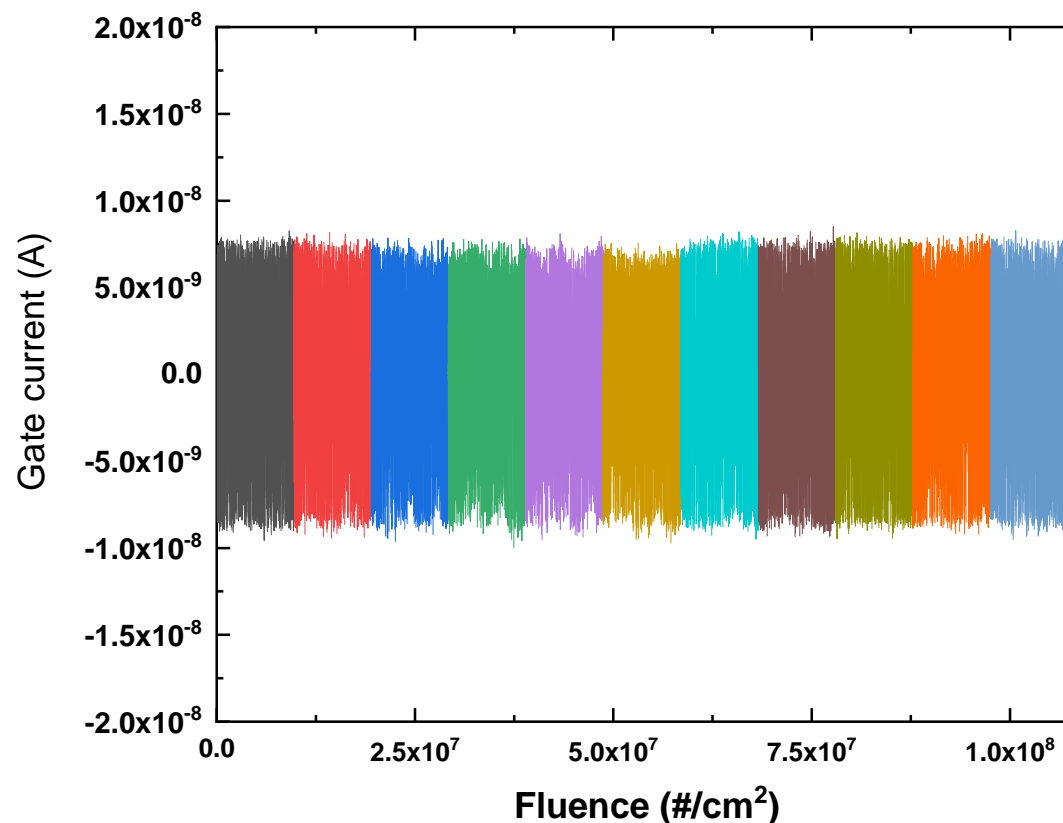
- No SEE detected up to  $1.1 \times 10^8$  #/cm<sup>2</sup> fluence

## Gate current

Each correspond to  
 $1 \times 10^7$  #/cm<sup>2</sup> fluence



## Drain current



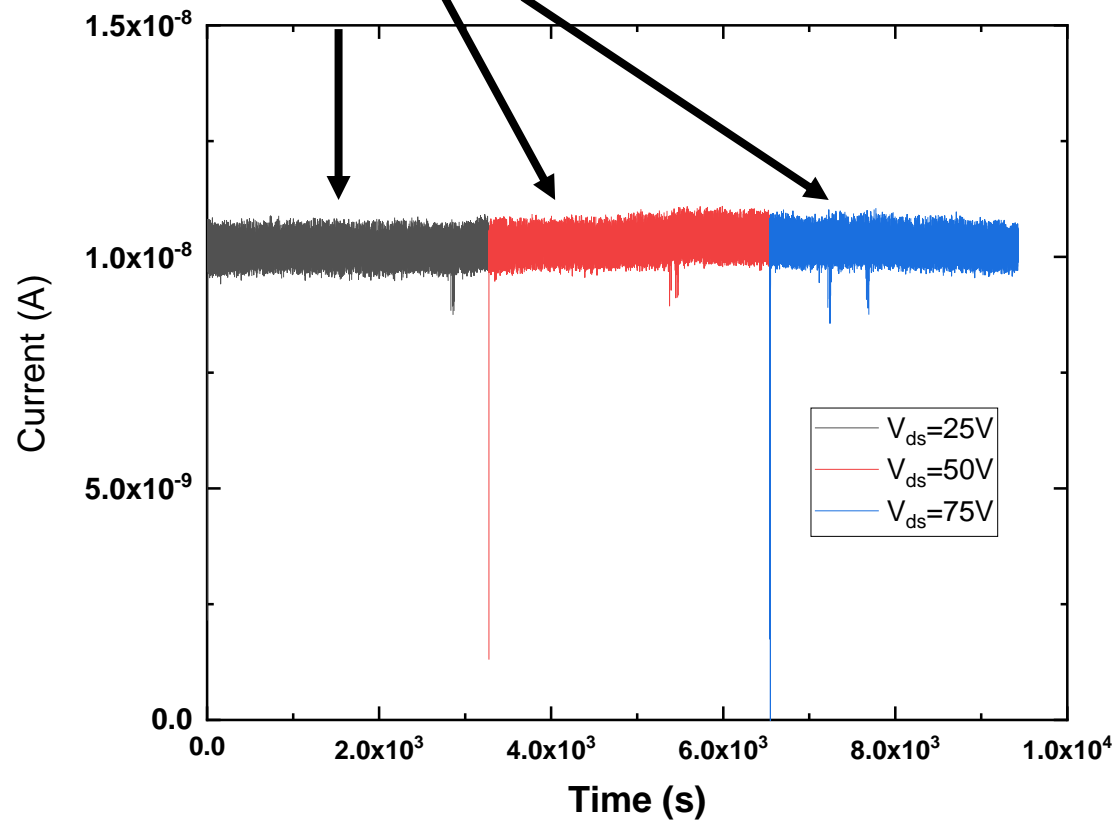
# Junction FET– $V_{ds}$ ramp

Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>40</sup> Ar	192 MeV (4.8 MeV/u)	26 $\mu$ m	10.8

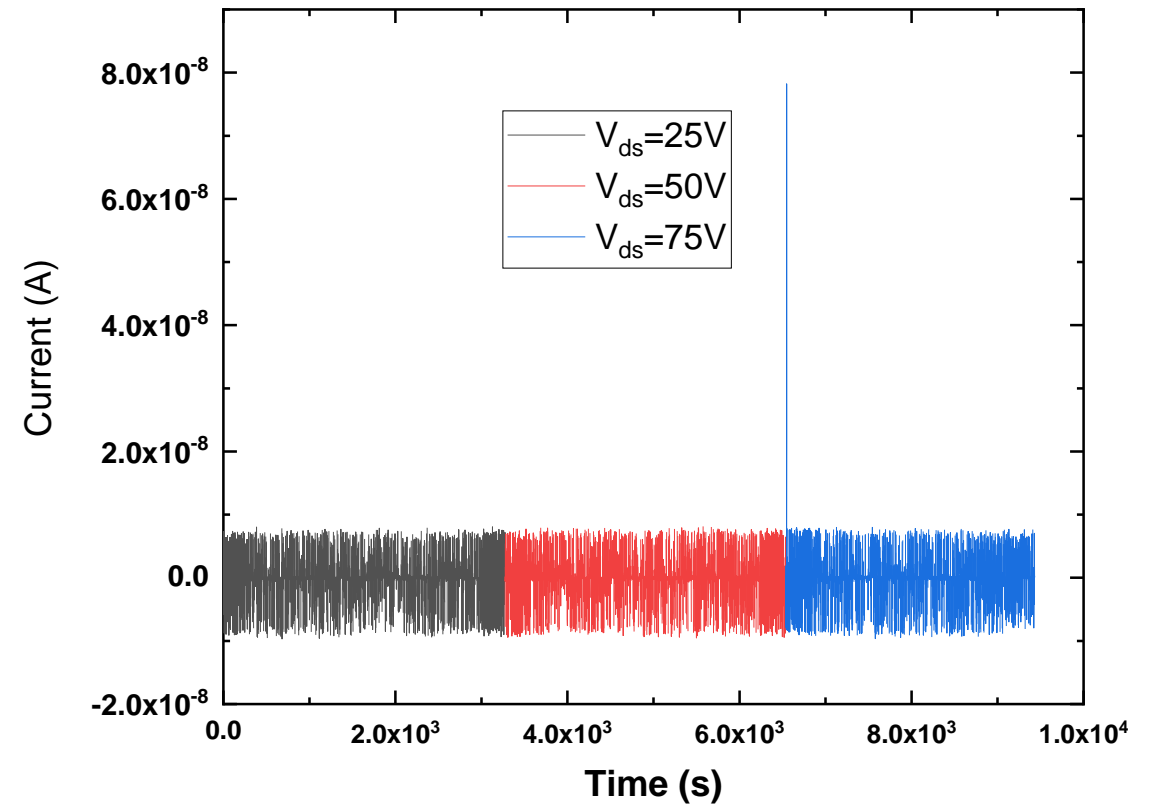
- No SEE detected up to  $V_{ds} = 75$  V

## Gate current

Each correspond to  $1 \times 10^7$  #/cm<sup>2</sup>  
fluence (non- cumulative)



## Drain current



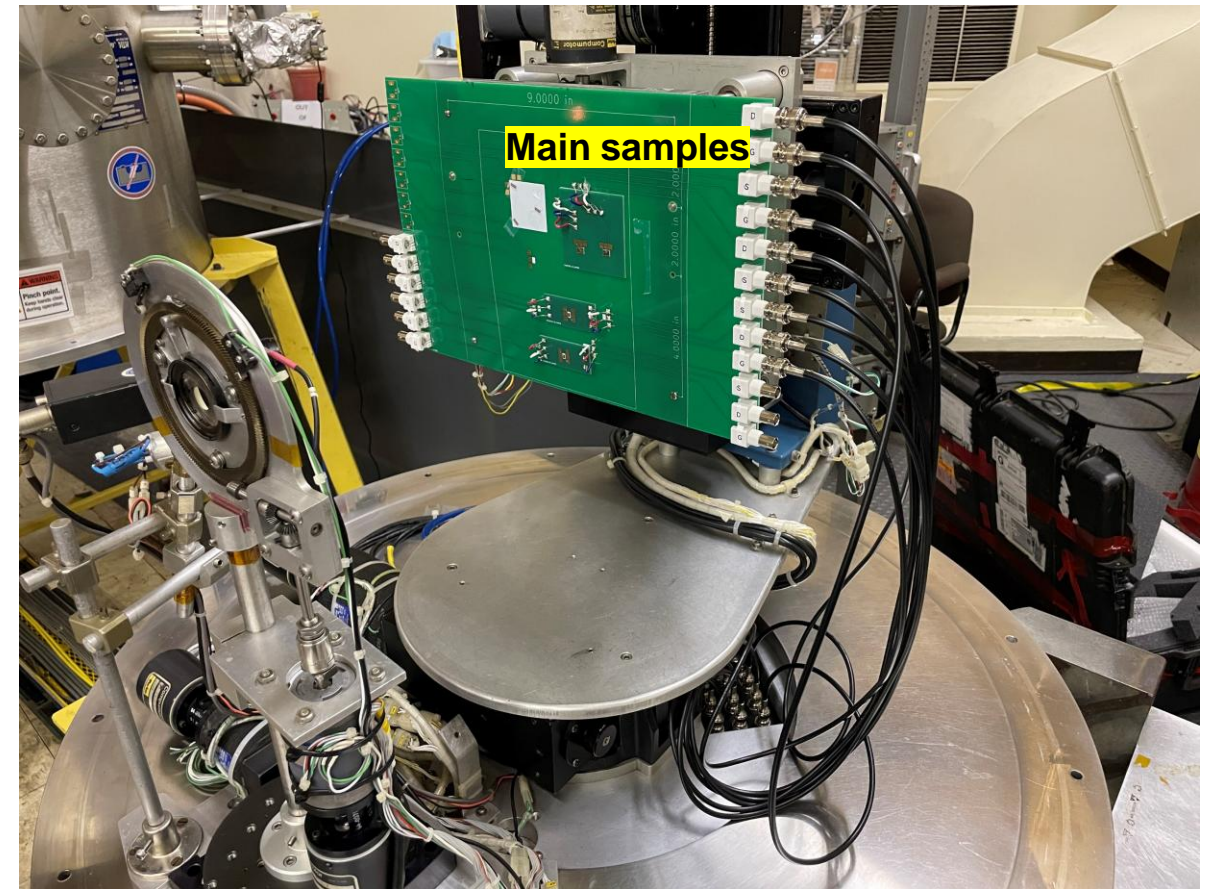
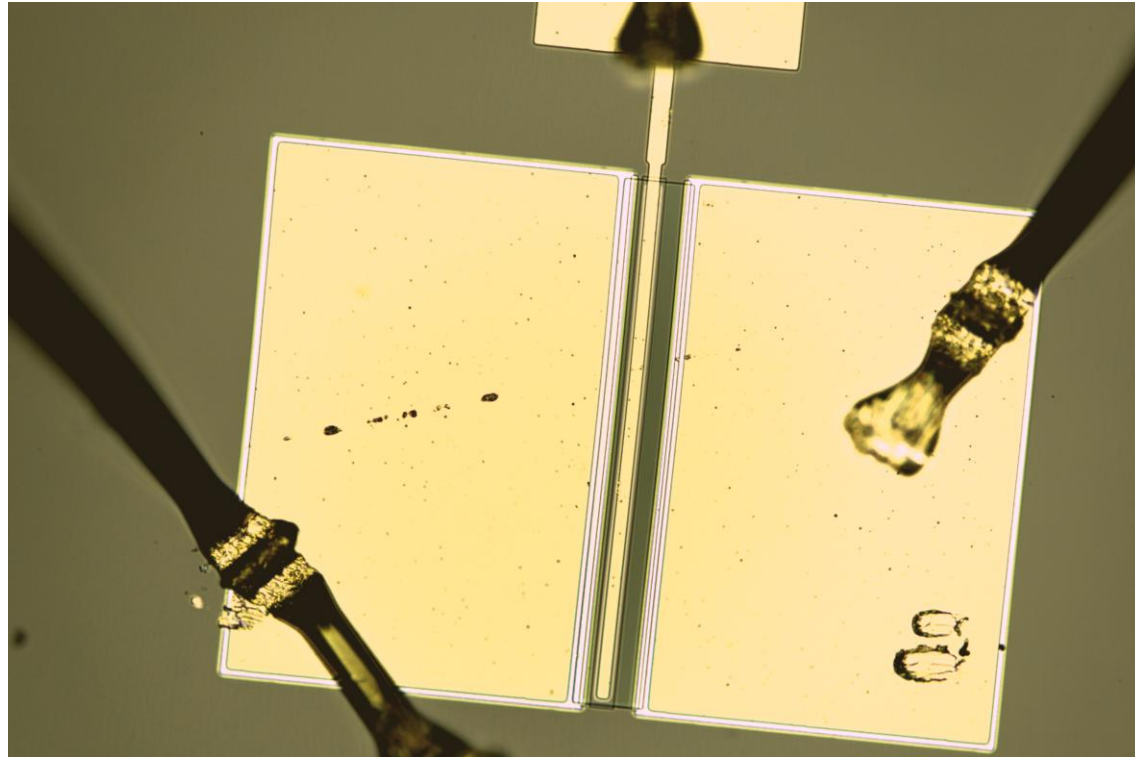
- ☐ GSI – 192 MeV Ar – On-site test
- ☒ **BNL – 333.7 MeV Au – On-site test**
- ☐ GSI – 950 MeV Au – Ex-situ test



# Overview

Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	333.7 MeV (1.71 MeV/u)	15.5 μm	64.09

- PSU fabricated JFET, wire bonded
- Device bias at off-state during irradiation ( $V_{ds}$  = variable,  $V_{gs}$  = -6 V)
- Broad beam covers full sample



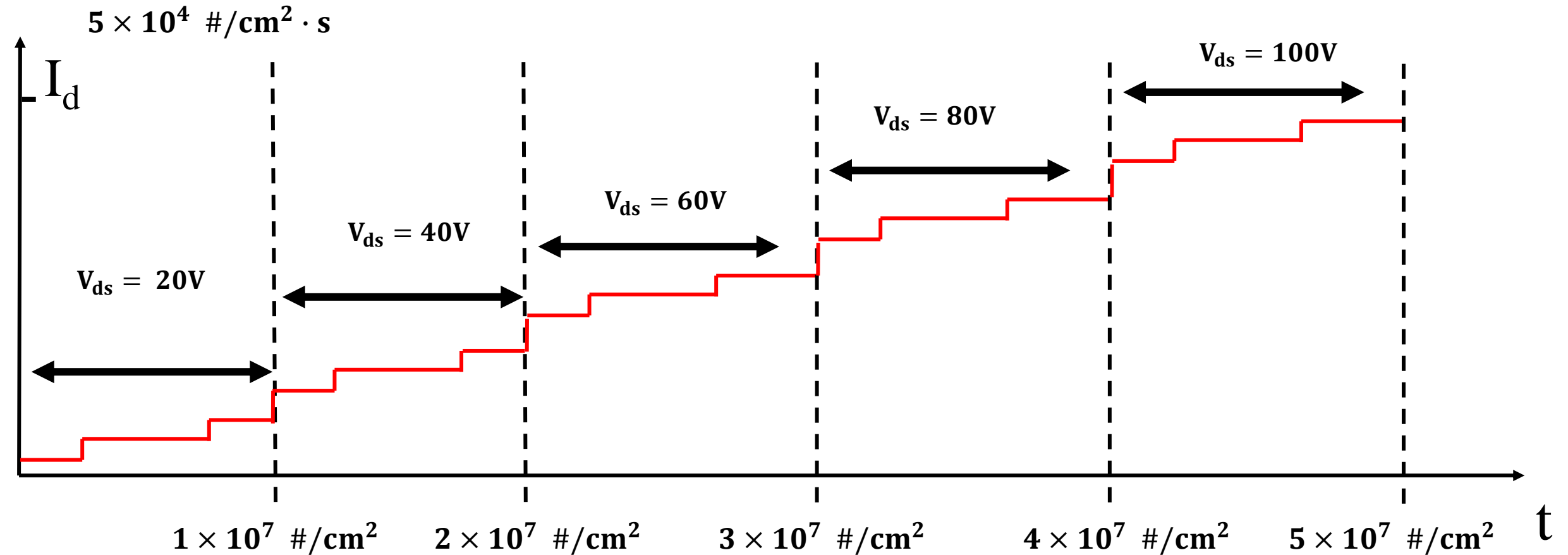


# Scanning recipe

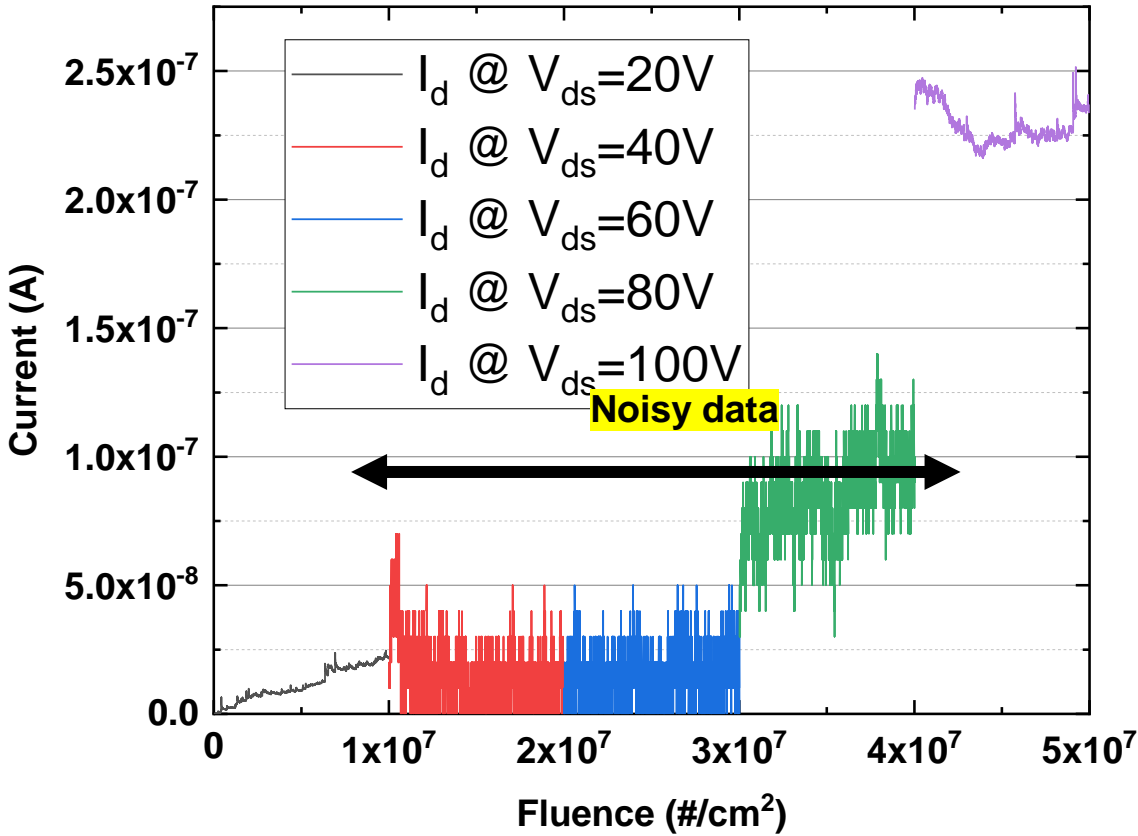
Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	333.7 MeV (1.71 MeV/u)	15.5 μm	64.09

Sampling interval : 50ms

$BV_{ds} = \sim 130V$

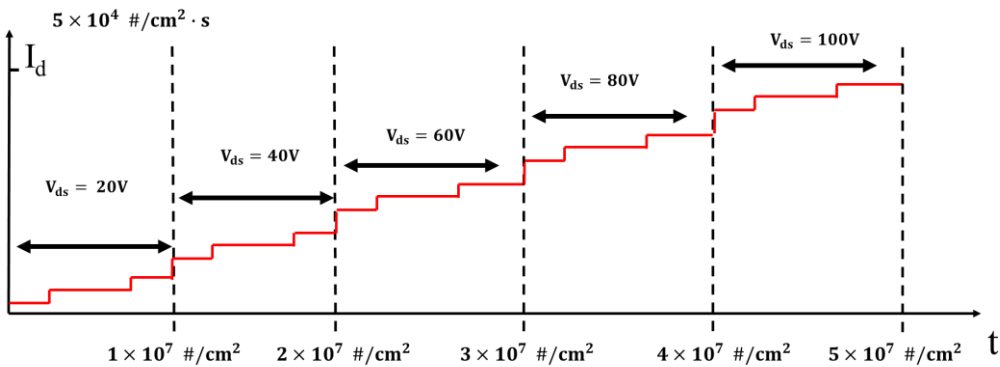


Ion	Energy	Range	LET (MeV/(mg/cm²))
<sup>197</sup> Au	333.7 MeV (1.71 MeV/u)	15.5 µm	64.09

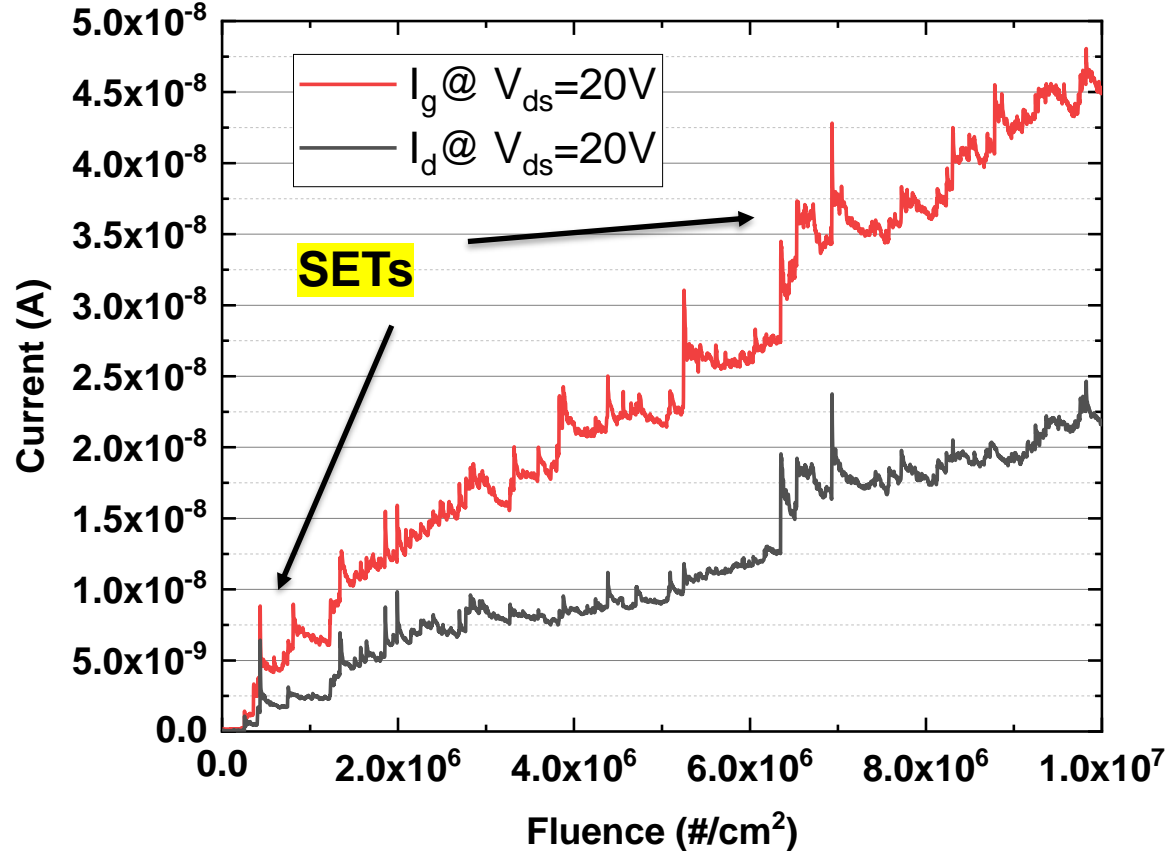
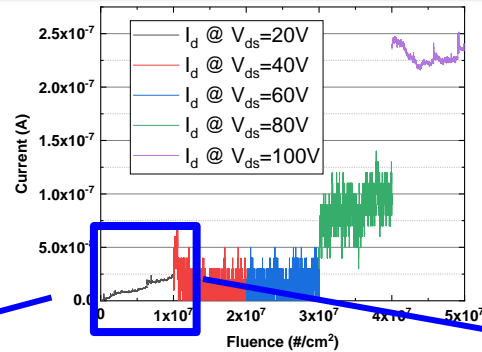


❖ Tool calibration likely caused the noisy data between 40~80V

- Gradual increase of off-state leakage current over fluence and V<sub>ds</sub>
- No destructive SEE observed

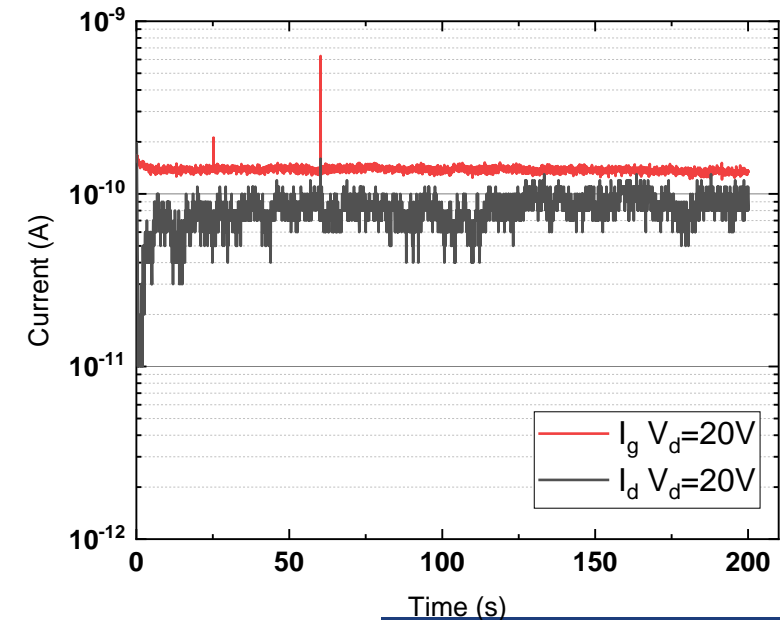


Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
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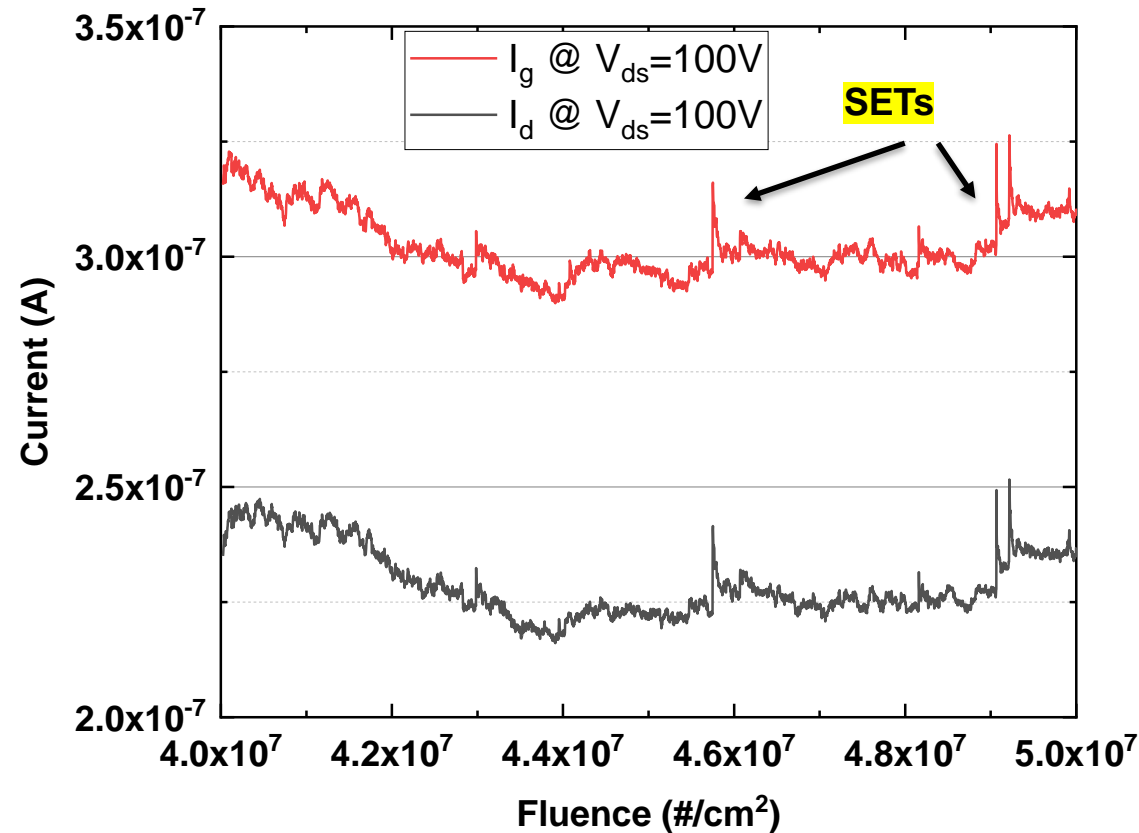
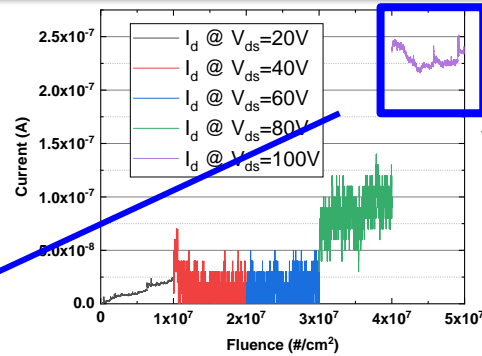
- Leakage current increasing constantly
- Each SET in  $I_d$  always correspond to one in  $I_g$ .

## Device transient without any radiation



# PSU JFET – $V_{ds} = 100\text{ V}$ @ $5e7\text{ \#/cm}^2$ fluence

Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	333.7 MeV (1.71 MeV/u)	15.5 μm	64.09

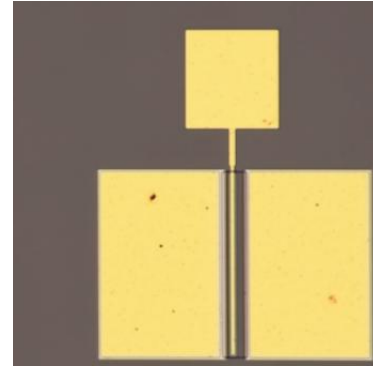
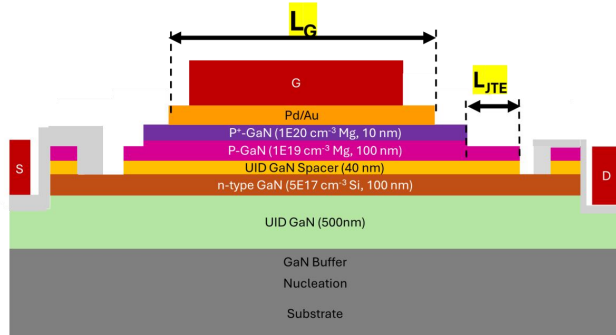


- SETs can still be observed
- Device leakage current stabilized
- No destructive SEE

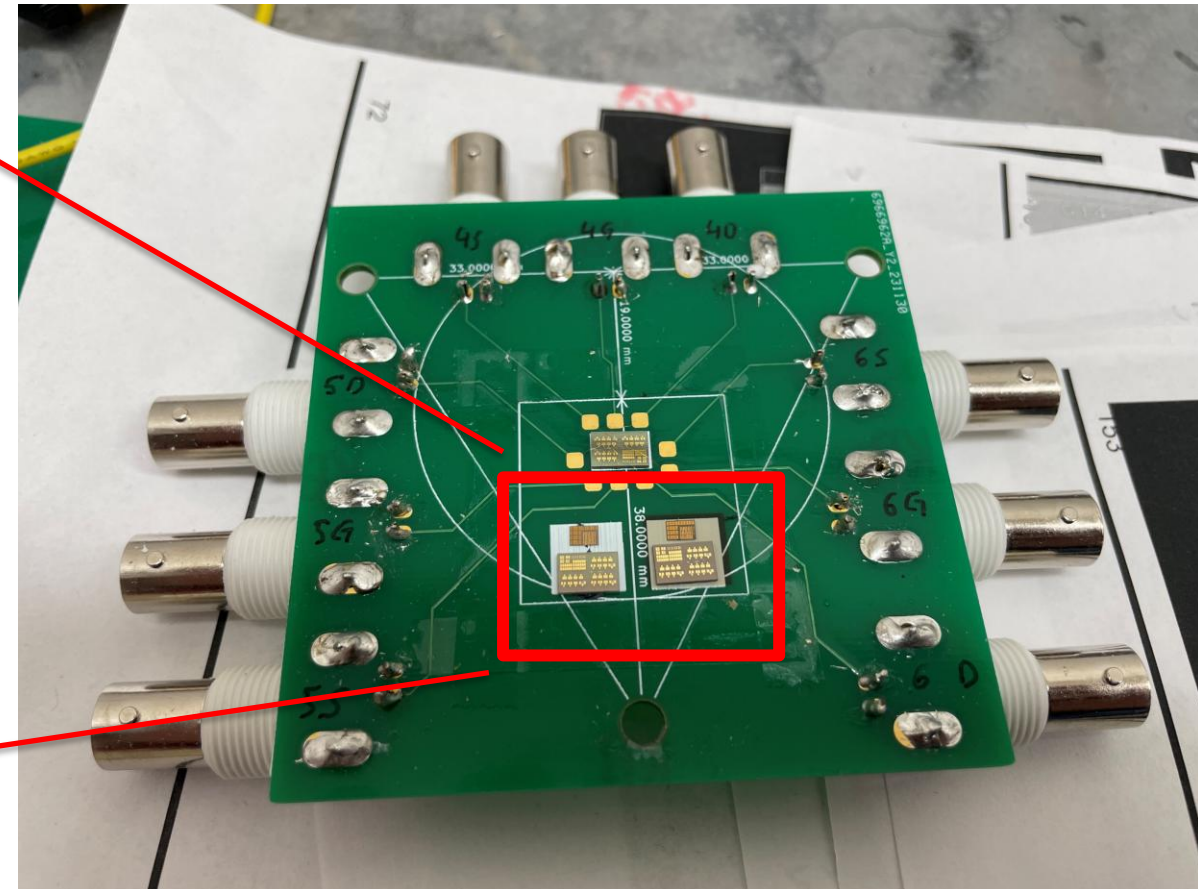
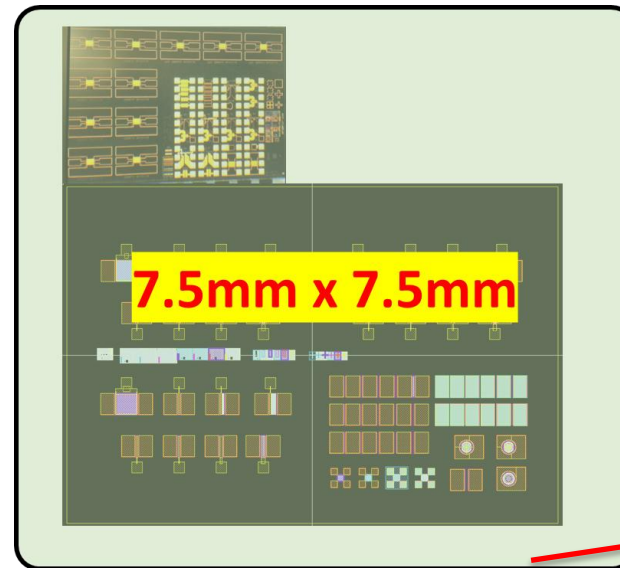
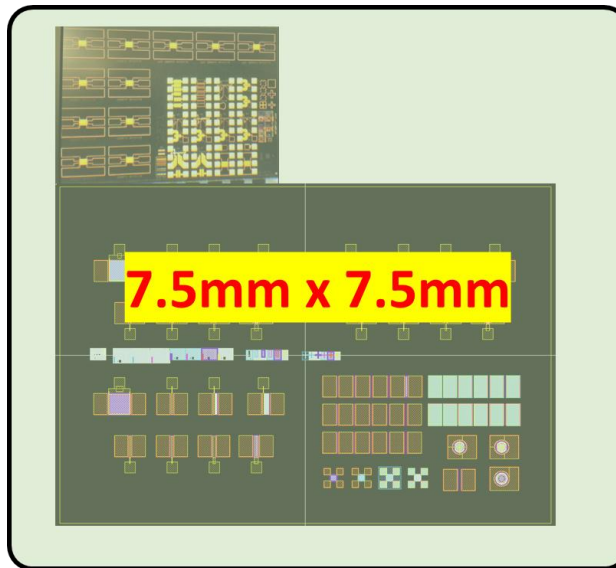
- ☐ GSI – 192 MeV Ar – On-site test
- ☐ BNL – 333.7 MeV Au – On-site test
- ☒ **GSI – 950 MeV Au – Ex-situ test**

# Overview

Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	950 MeV (4.8 MeV/u)	30 μm	72.4



PSU made JFET samples, broad beam irradiation



Fluence  $1 \times 10^7 \text{ \#}/\text{cm}^2$

Fluence  $5 \times 10^{11} \text{ \#}/\text{cm}^2$



# PSU FETs – Au ion fluence variance

Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
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- Extreme high fluence destroy the device

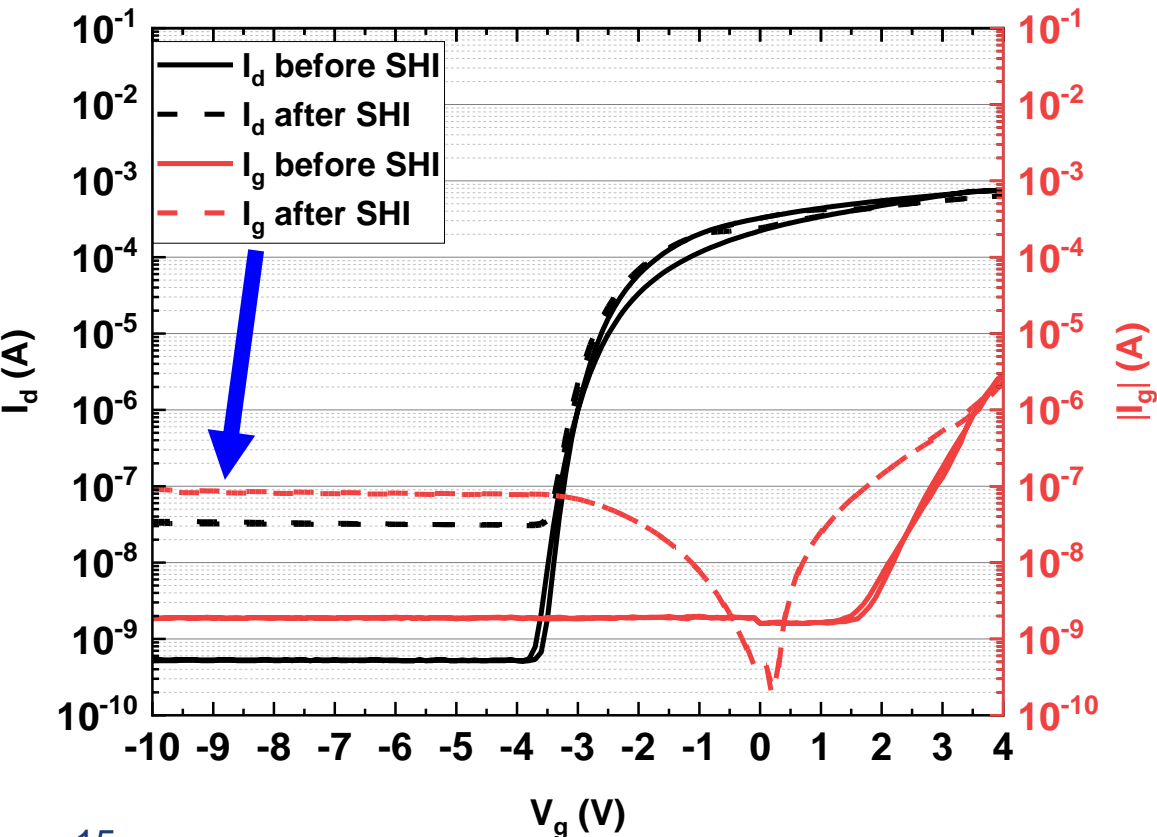
Transfer IV

Bias:  $V_g = -10$  to  $4V$ ;  $V_d = 0.5V$

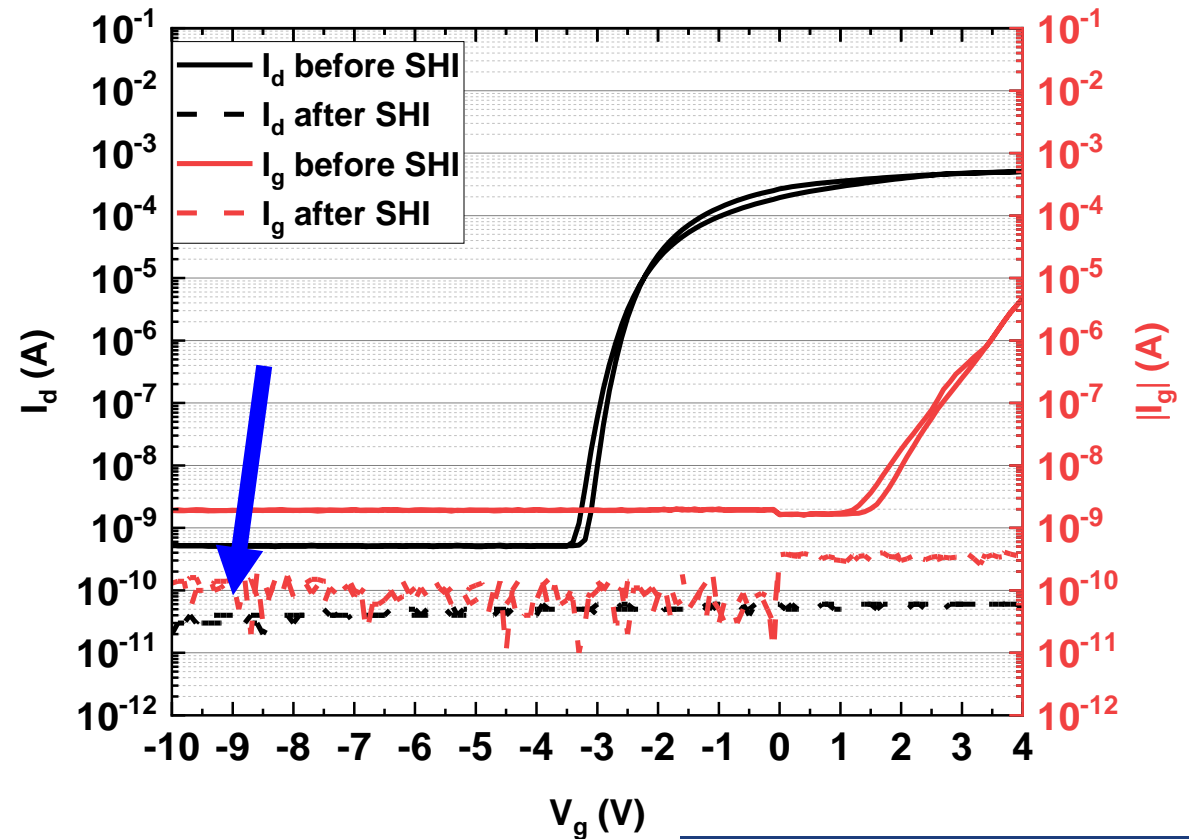
JFET

$L_g = 10\mu m$ ,  $L_{JTE} = 10\mu m$

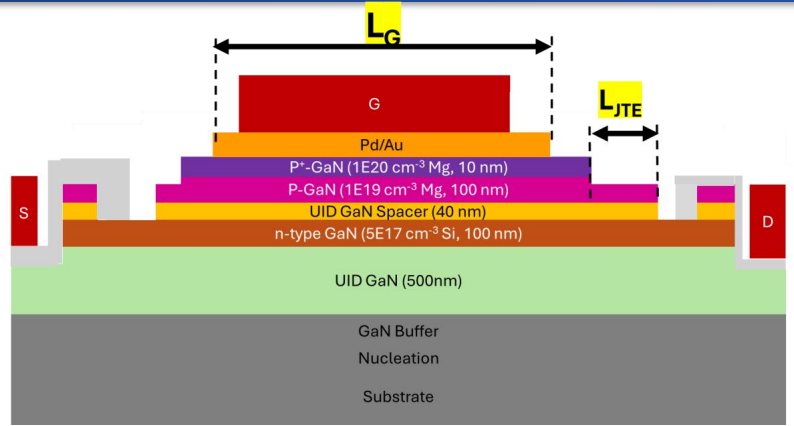
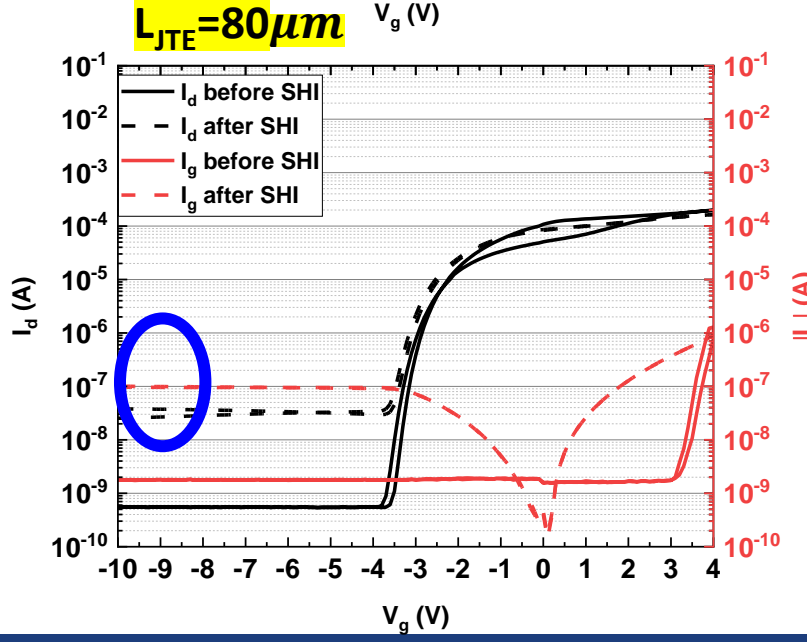
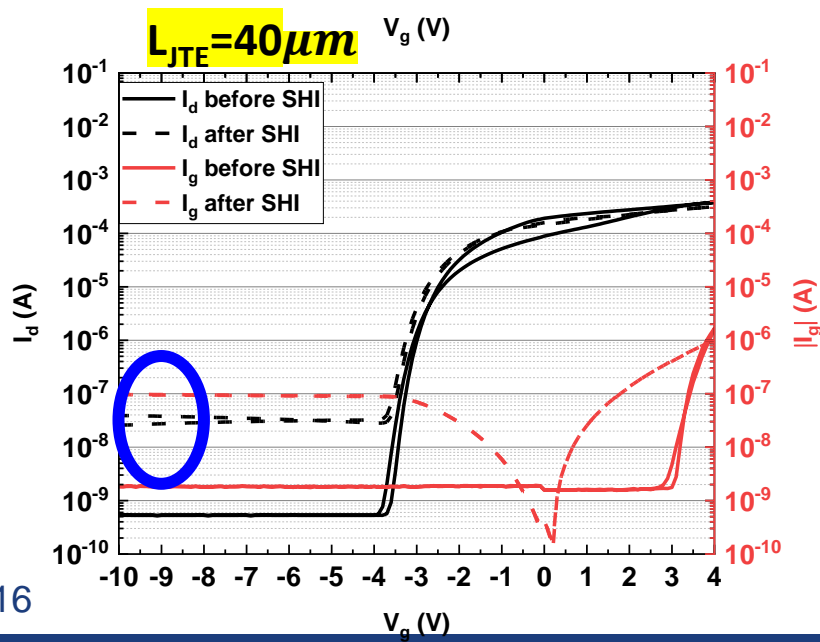
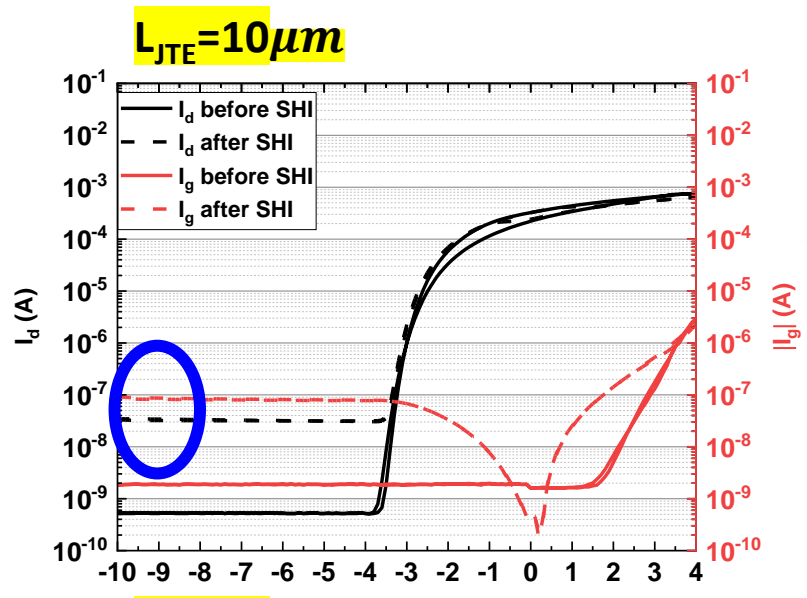
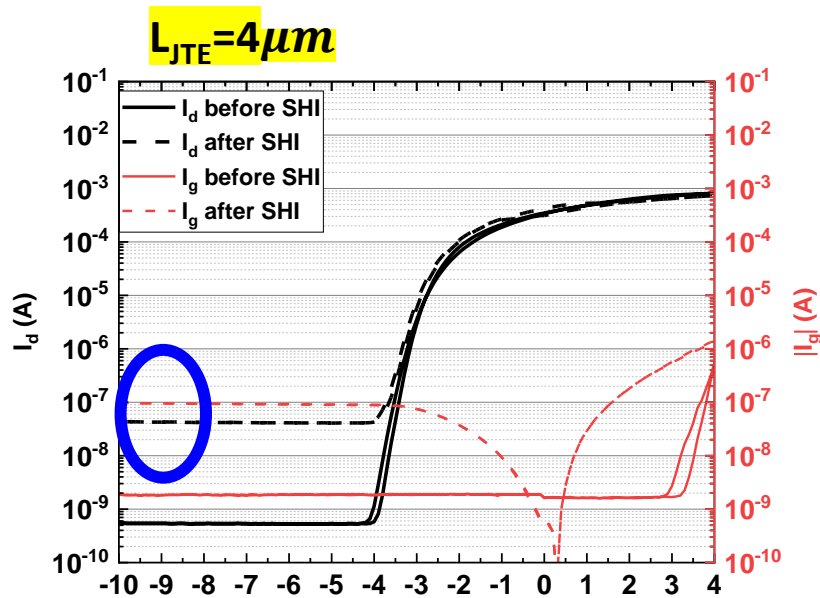
Au fluence =  $1 \times 10^7 \# / cm^2$



Au fluence =  $5 \times 10^{11} \# / cm^2$



Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
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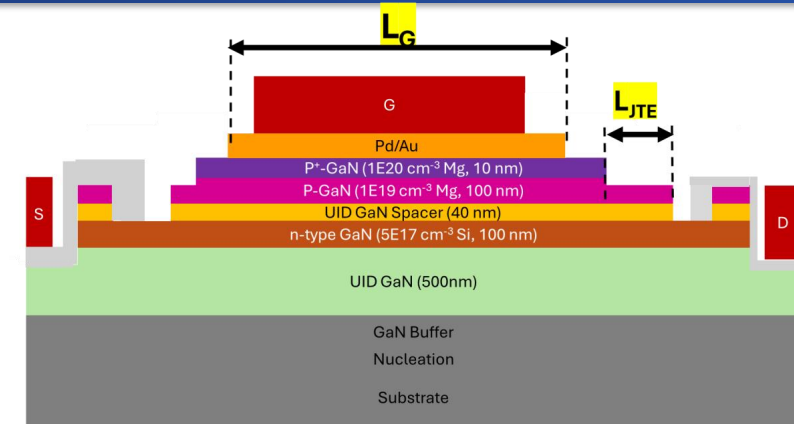
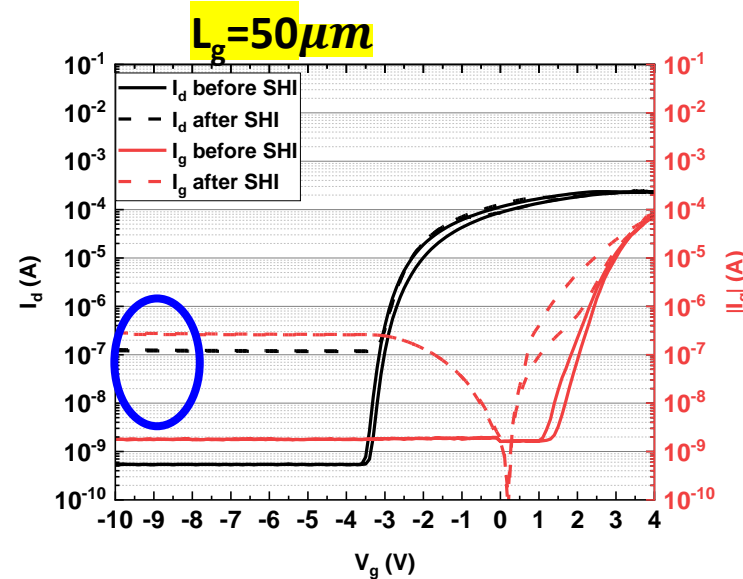
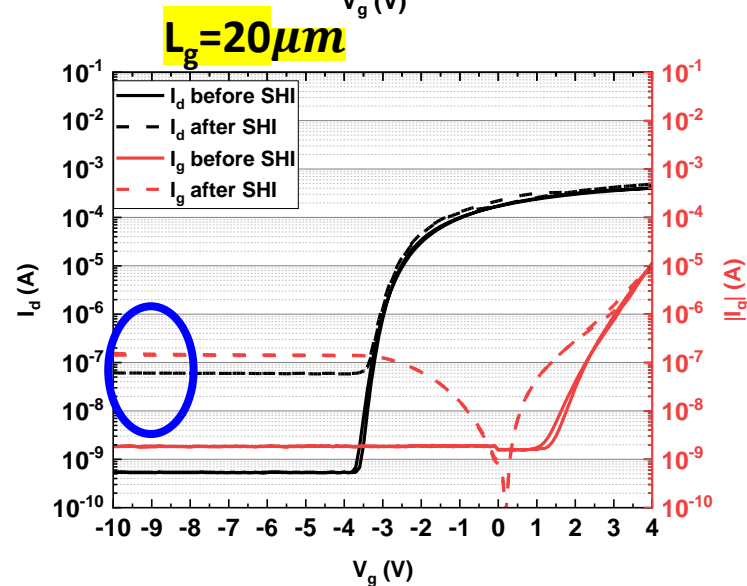
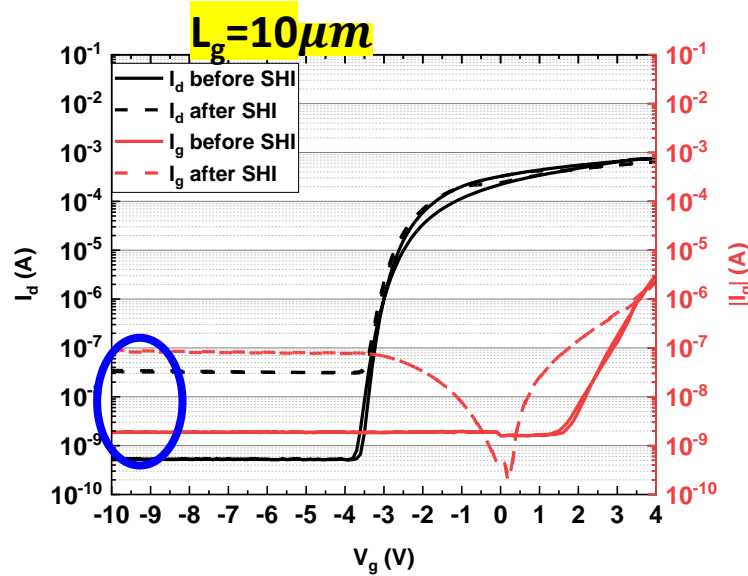
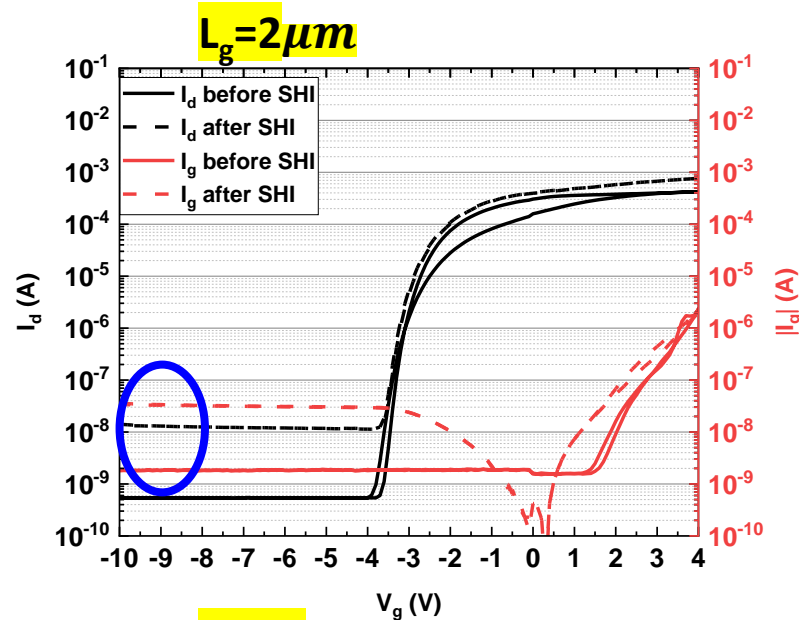


**Transfer IV**  
**Bias:  $V_g = -10$  to  $4\text{V}$ ;  $V_d = 0.5\text{V}$**

No noticeable dependence on JTE length.

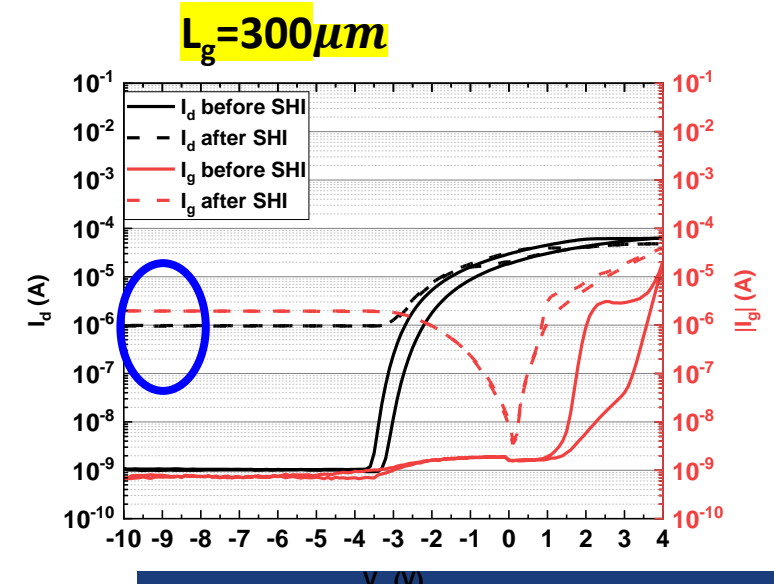
Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	950 MeV (4.8 MeV/u)	30 $\mu\text{m}$	72.4

Drain / gate current increased after radiation and showed dependency on  $L_g$ .



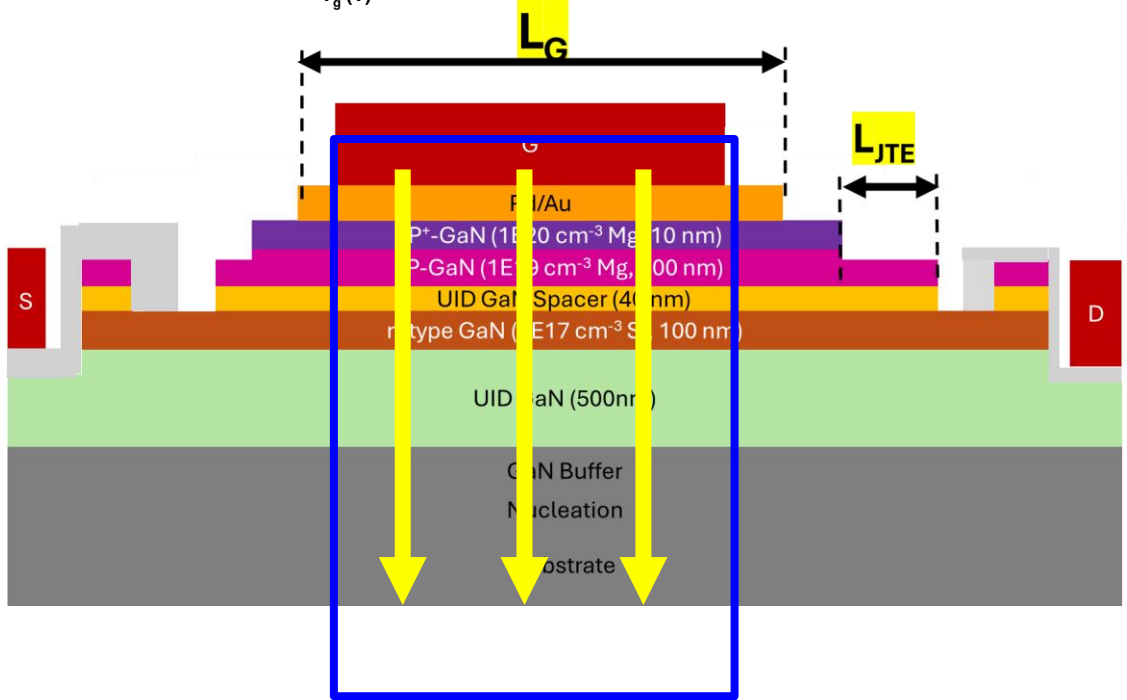
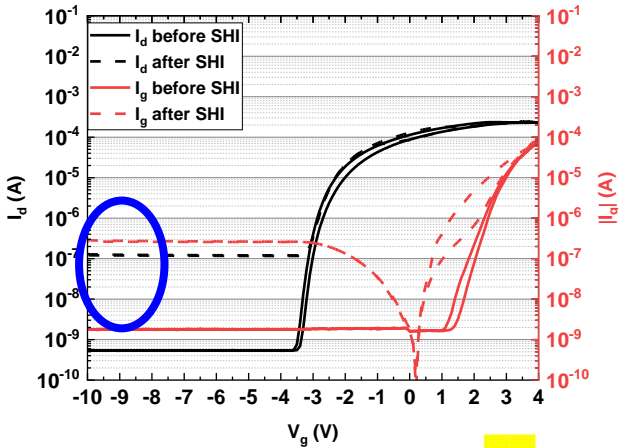
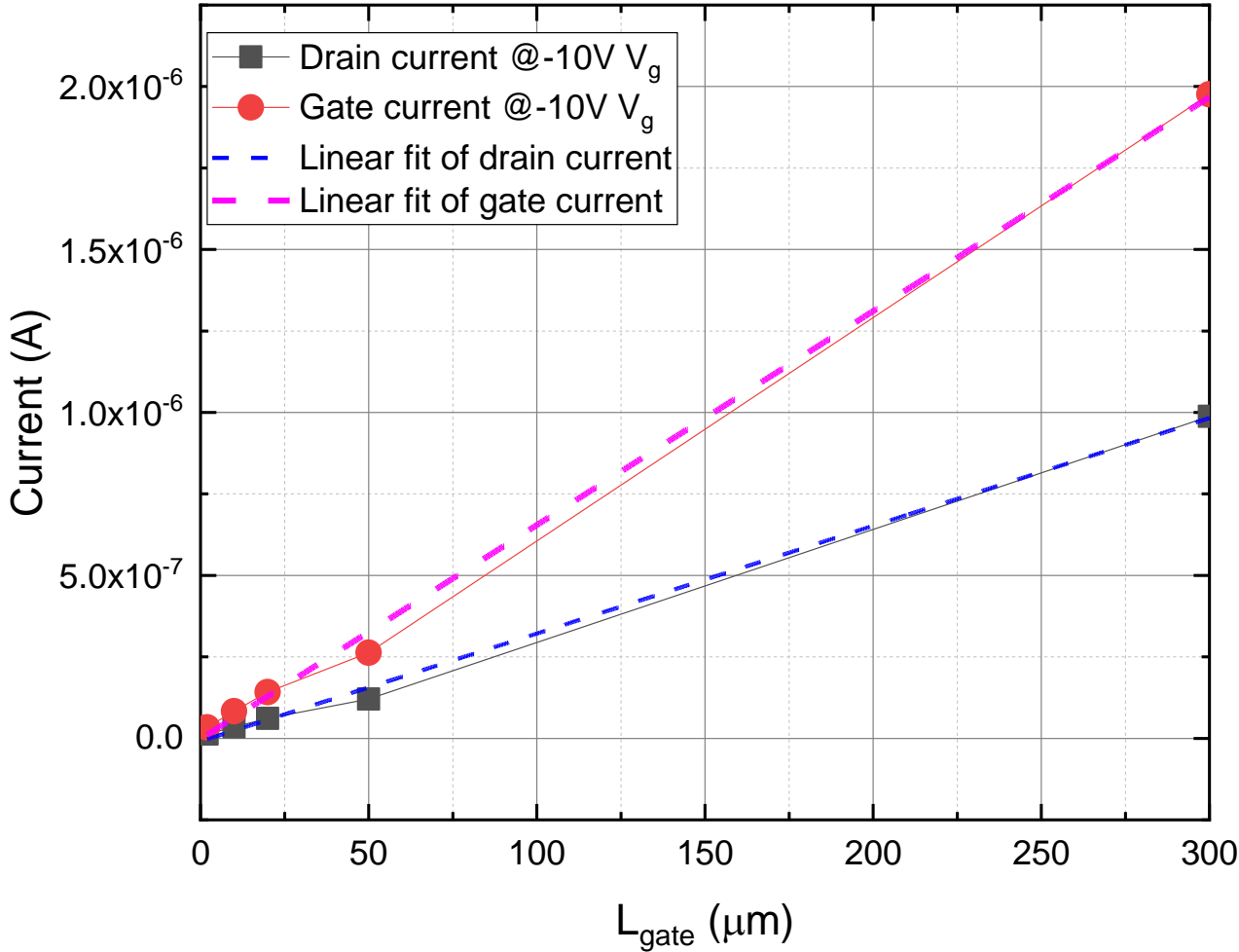
Transfer IV

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Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	950 MeV (4.8 MeV/u)	30 μm	72.4

- The leakage current is proportional to gate length (gate junction area) - > indicating junction leakage



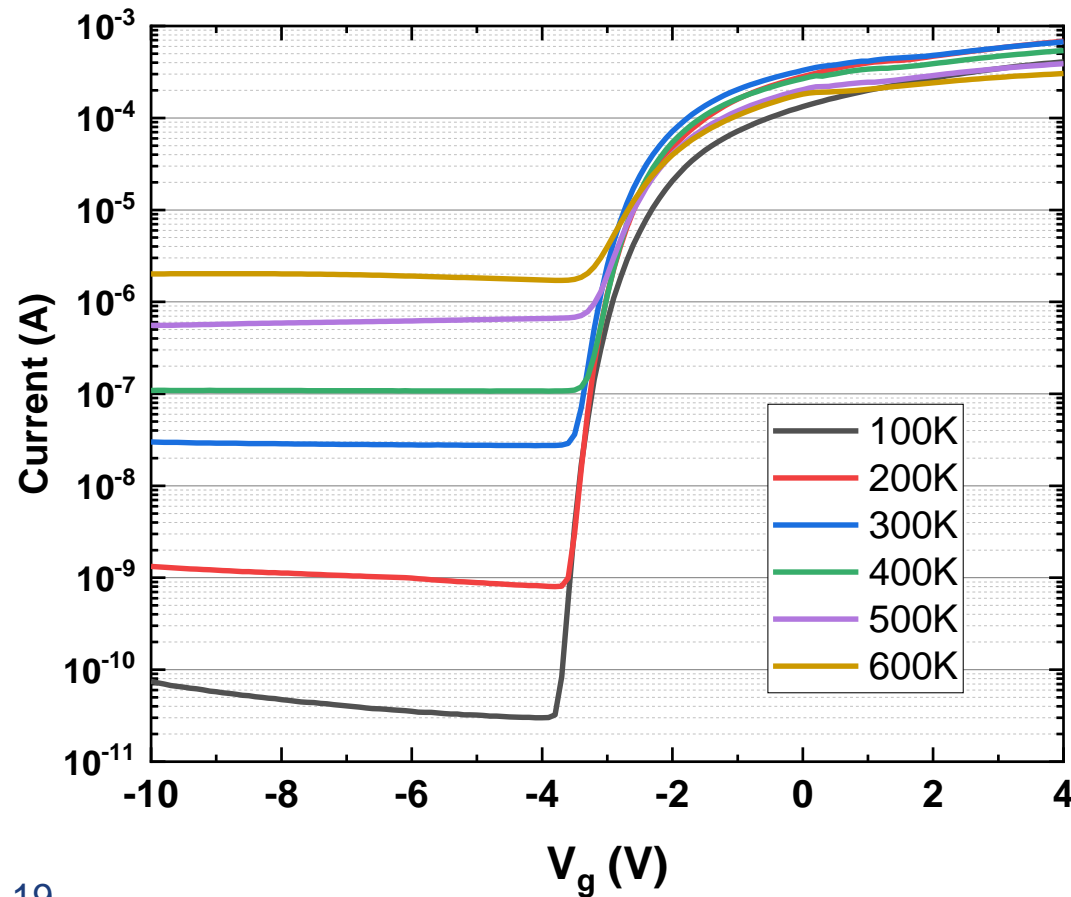
Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
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- The leakage current is strong function of temperature

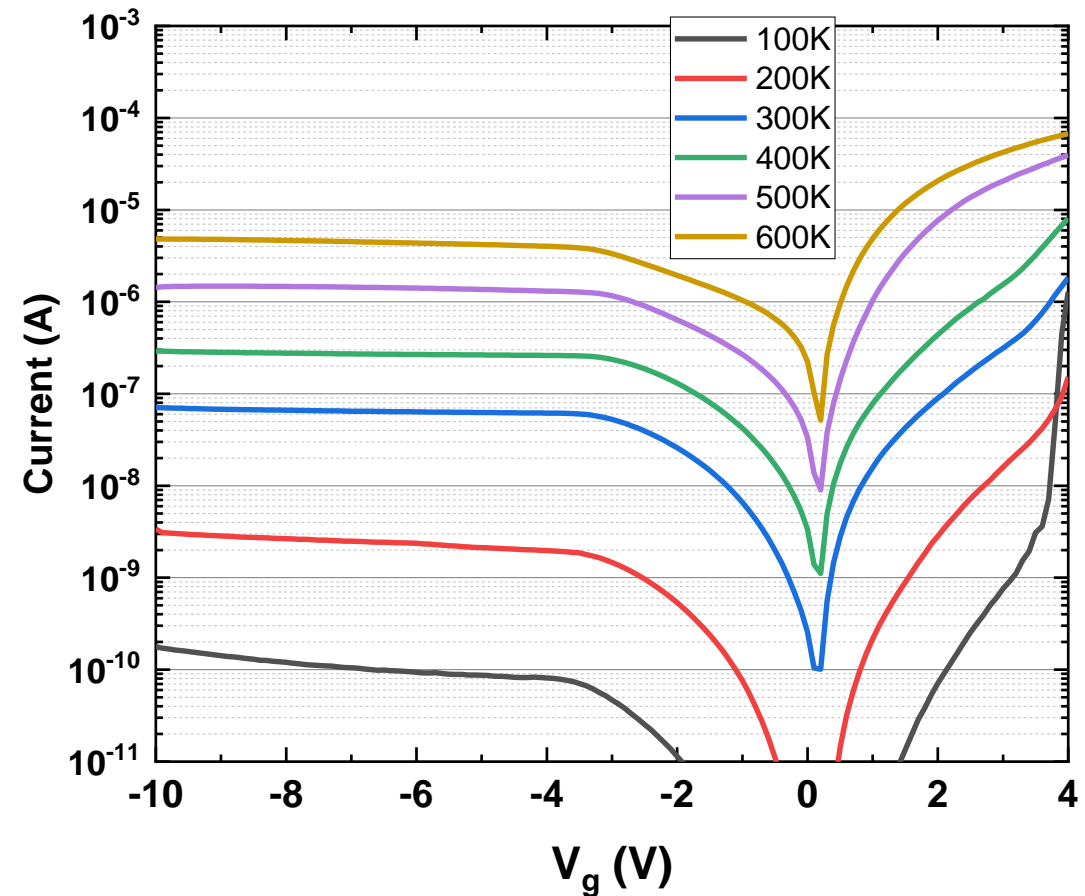
JFET

$L_g=10\mu\text{m}$ ,  $L_{JTE}=10\mu\text{m}$

**Drain current**

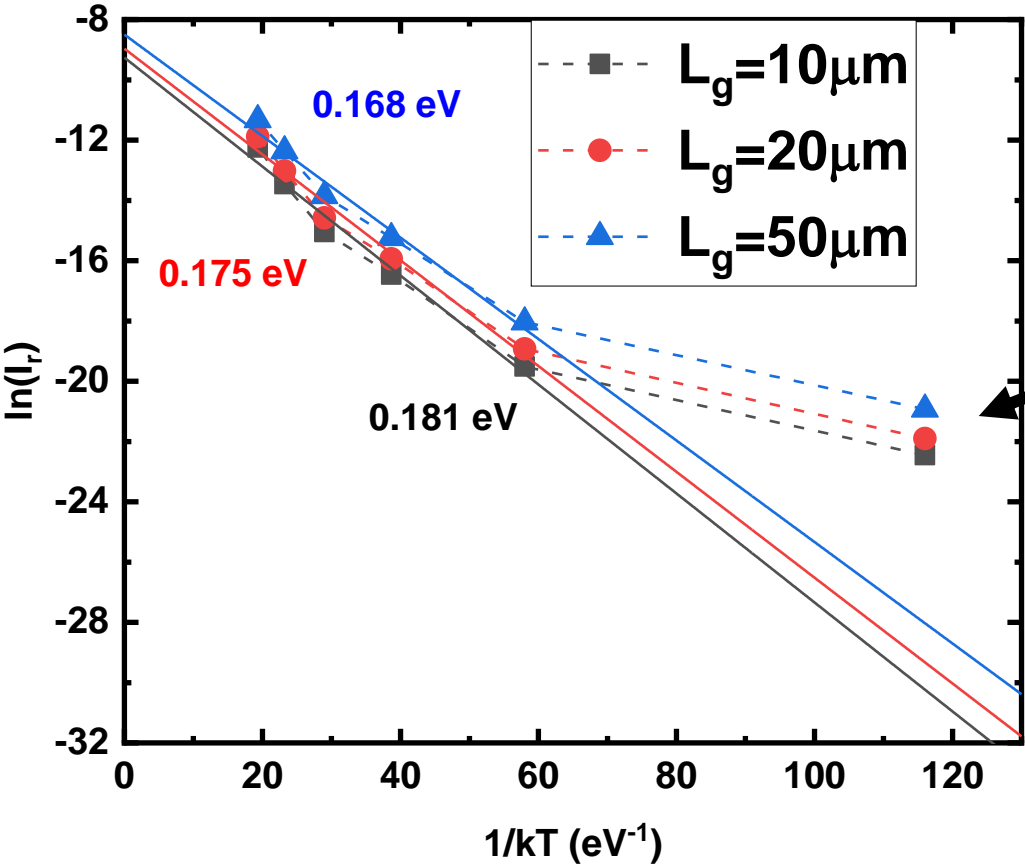


**Gate current**



Ion	Energy	Range	LET (MeV/(mg/cm <sup>2</sup> ))
<sup>197</sup> Au	950 MeV (4.8 MeV/u)	30 μm	72.4

Arrhenius plot  $E_a$  extraction



Activation energy = 0.168 ~ 0.181 eV

100 K data point deviated from thermal current – further study required for investigating the mechanism



# Summary

## ❑ GSI – 192 MeV Ar – On-site test

- No SEE observed

## ❑ BNL – 333.7 MeV Au – On-site test

- Constantly increased leakage over fluence
- Can identify SET current peaks but did not lead to any destructive SEE

## ❑ GSI – 950 MeV Au – Ex-situ test

- Leakage current increased after irradiation
- Is linearly dependent to junction area indicating junction leakage
- Temperature dependent leakage –

Activation energy  $E_a = 0.16 \sim 0.18$  eV

## Next

- Beam irradiation with improved PSU devices, and further components modified based on the JFET
- Additional electrical characterization for leakage mechanism study

**Thank you!**